

## ROTHWELL, FIGG, ERNST &amp; MANBECK

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FACSIMILE TRANSMITTAL SHEET

DATE: August 16, 2005

TO: Filing Receipt Corrections Fax No. 703-746-9195  
U.S. Patent & Trademark Office

FROM: Victoria Deffenbaugh

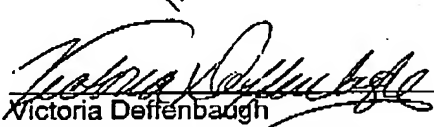
OUR REF.: 3225-102

Patent/Appn. No.: 10/510,640  
Filed: December 2, 2004

## MESSAGE:

Filed by Facsimile Transmission

I hereby certify that the foregoing, correction request, and marked filing receipt is being filed with the U.S. Patent and Trademark Office via facsimile transmission on the date of my signature.

  
Victoria Deffenbaugh Date: 8/16/05  
Patent Prosecution Paralegal  
Rothwell, Figg, Ernst & Manbeck, p.c.

Number of Pages Including This Transmittal Sheet: 5

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## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Appl. No. : 10/510,640  
Applicant : Khim Hong NG et al.  
Filed : December 2, 2004  
TC/A.U. : 2812  
Examiner :

Docket No. : 3225-102  
Customer No. : 06449  
Confirmation No. : 1877

**REQUEST FOR CORRECTED FILING RECEIPT**

Director of the United States Patent  
and Trademark Office  
P.O. Box 1450  
Alexandria, Virginia 22313-1450

Dear Sir:

Please issue a corrected filing receipt for the above-referenced application. An error was found under the "Assignment for Published Patent Application" section of the Office Filing Receipt. Please correct the following information as claimed by the applicant listed on the Application Data Sheet submitted with the initial filing of this application:

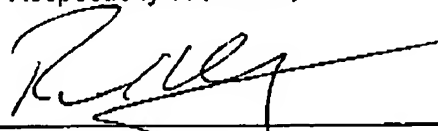
**---Assignment for Published Patent Application**

SYSTEMS ON SILICON MANUFACTURING COMPANY PTE. LTD., Singapore,  
SINGAPORE ---

A copy of the filing receipt with the correction to be made marked in ink is attached for your reference.

Respectfully submitted,

By



Richard Wydeven  
Attorney for Applicants  
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## UNITED STATES PATENT AND TRADEMARK OFFICE

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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/510,640	12/02/2004	2812	1110	3225-102	6	12	1

CONFIRMATION NO. 1877

6449

ROTHWELL, FIGG, ERNST & MANBECK, P.C.  
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WASHINGTON, DC 20005

FILING RECEIPT

  
\*OC00000016490355\*

Date Mailed: 07/13/2005

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

## Applicant(s)

Khim Hong Ng, Singapore, SINGAPORE;  
Chin Ling Pong, Singapore, SINGAPORE;

## Assignment For Published Patent Application

PTE,  
SYSTEMS ON SILICON MANUFACTURING COMPANY-PEP. LTD, Singapore, SINGAPOREPower of Attorney: The patent practitioners associated with Customer Number 6449.

## Domestic Priority data as claimed by applicant

This application is a 371 of PCT/SG03/00290 12/23/2003

## Foreign Applications

Projected Publication Date: 10/20/2005

Non-Publication Request: No

Early Publication Request: No

Title

RECEIVED/FACILITIES  
ROTHWELL FIGG ERNST & MANBECK  
FILE NO. 3225-102  
FAC PROC. INT.JUL 18 2005 *mb*

Method of etching a semiconductor device

Preliminary Class

438

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